

Amendments to the Claims

In the Claims:

Please amend the claims as follows (the changes in these Claims are shown with ~~strikethrough~~ for deleted matter and underlines for added matter).

1. (Twice Amended) A plasma treatment equipment having a chamber for performing plasma treatment, the plasma treatment equipment comprising:
a plasma excitation electrode to which a power for plasma excitation is supplied,
the plasma excitation electrode being provided in the chamber; and
a susceptor electrode that is opposed to the plasma excitation electrode provided
in the chamber, the susceptor electrode having the same DC potential as that of a
chamber wall of the chamber, the susceptor electrode being an electrode into which a
high frequency electric current based on the power for plasma excitation flows after
passing through a plasma space;
wherein the chamber wall of the chamber and the susceptor electrode are AC
shorted to each other by a plurality of metal plates, the susceptor electrode is connected
to the chamber wall of the chamber by a bellows provided in the chamber, the plurality
of metal plates are disposed so as to be electrically parallel with the bellows[Plasma
treatment equipment in which a chamber wall and a susceptor electrode having the
same DC potential are AC shorted to each other].
4. (Amended) The plasma treatment equipment according to claim 3, wherein
[said susceptor electrode is shorted to said chamber wall by a metal plate, said] each
metal plate [being] is connected between the short point on the bottom wall and a
second short point on a shield of the susceptor electrode.
5. (Amended) The plasma treatment equipment according to claim [3]4, wherein
the said metal plate is inclined with respect to the bottom wall, and an angle formed
between said metal plate and the bottom wall is less than 45 degrees.

13. (Twice Amended) A plasma treatment equipment having a chamber for performing plasma treatment, the plasma treatment equipment comprising:

a plasma excitation electrode to which a power for plasma excitation is supplied,
the plasma excitation electrode being provided in the chamber;

a susceptor electrode that is opposed to the plasma excitation electrode provided
in the chamber; and

an electrode shield of the susceptor electrode in the chamber,
wherein at least one of the susceptor electrode and the electrode shield thereof
has the same DC potential as that of a chamber wall of the chamber,

the susceptor electrode being an electrode into which a high frequency electric
current based on the power for plasma excitation flows after passing through a plasma
space,

the chamber wall of the chamber and at least one of the susceptor electrode and
the electrode shield thereof are AC shorted to each other by a plurality of metal plates,
and

the susceptor electrode is connected to the chamber wall of the chamber by a
bellows provided in the chamber, the plurality of metal plates are disposed so as to be
electrically parallel with the bellows.

23. (Twice Amended) A plasma treatment equipment having a chamber for performing plasma treatment, the plasma treatment equipment comprising:

a plasma excitation electrode to which a power for plasma excitation is supplied,
the plasma excitation electrode being provided in the chamber;

a susceptor electrode that is opposed to the plasma excitation electrode provided
in the chamber; and

an electrode shield of the susceptor electrode in the chamber, the electrode
shield disposed adjacent to the susceptor electrode,

wherein at least one of the susceptor electrode and the electrode shield thereof
has the same DC potential as that of a chamber wall of the chamber,

the susceptor electrode being an electrode into which a high frequency electric current based on the power for plasma excitation flows after passing through a plasma space,

the chamber wall of the chamber and at least one of the susceptor electrode and the electrode shield thereof are AC shorted to each other by a plurality of metal plates, each metal plate having a first end connected to a first short point on the shield and a second end connected to a second short point on an inner surface of the bottom wall of the chamber, and

the susceptor electrode is connected to the chamber wall of the chamber by a bellows provided in the chamber, the plurality of metal plates are disposed so as to be electrically parallel with the bellows.